

Systematic investigation of 24 GeV/c proton-irradiated Micron pad detectors made of different silicon materials

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Outline

- Introduction
- Studied sensors and irradiation details
- IV/CV results
- TCT & CCE results
 - Setup and sample preparation (Al-etching)
 - Results for non-irradiated diodes
- Conclusion & outlook

Motivation:

- Radiation hardness limits of present silicon detector systems not sufficient for Luminosity upgrade for LHC
→ integrated radiation doses on the inner detector layers up to $2e16$ n/cm²

Problem of radiation damage in the bulk:

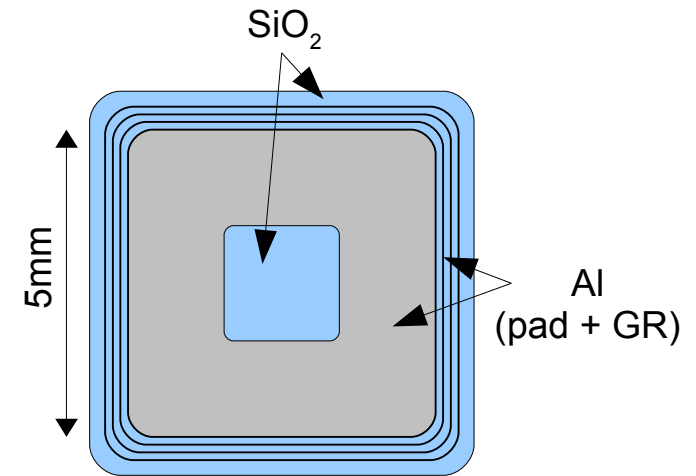
- Modification of basic electrical properties in silicon sensors
→ I_{leak} increase, V_{fd} change, CCE decrease
(charge trapping, modification of internal electric field distribution)
- Main source of SNR degradation

Main objectives of this work (within RD50):

- Characterisation of new silicon sensor types in terms of operating ability beyond such irradiation levels (i.e. long-term impacts)
- Deeper insight into underlying physics mechanisms (e.g. E-field distribution)

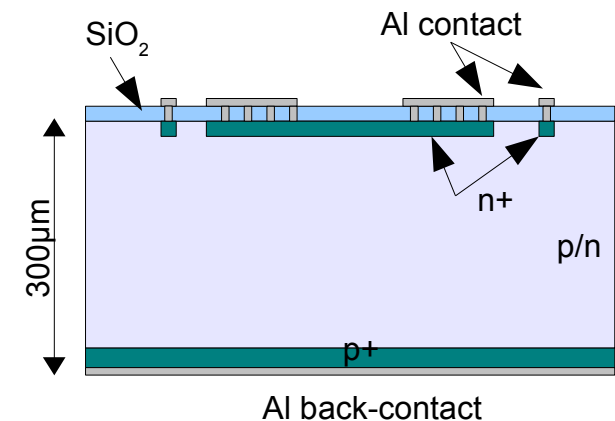
Common RD50 4" wafer production (2010) of MICRON Semiconductor Ltd. (UK)

- Pad and strip detectors
- p- and n-type FZ and MCz
- Thickness $\sim 300\mu\text{m}$
- Resistivity $\rho = 1\div 30 \text{ k}\Omega\text{cm}$



Non-irradiated data

Material	V _{fd} [V]	N _{eff} [cm ⁻³]	SIMS (O ₂ -conc. [cm ⁻³])
FZ n-in-p	13.6	1.96e11	2.2e16
MCz n-in-p	12.7	1.78e11	4.4e17
FZ p-in-n	21.2	-2.78e11	4.0e16
MCz p-in-n	62.2	-11.15e11	4.7e17
FZ n-in-n	18.6	-2.67e11	2.2e16
MCz n-in-n	-	-	4.0e17



- 24 GeV/c protons at CERN PS
- Flux: $1 \div 3 \times 10^{13}$ p/cm² h
- Annealing during irradiation ($\sim 27^\circ\text{C}$)
- Stored in freezer after irradiation

→ fluences received [p/cm²]: 5.85e13, 1.03e14, 5.31e14, 9.84e14, 1.95e15, 4.42e16

($\Phi_{\text{eq}} = 3.63\text{e}13, 6.39\text{e}13, 3.29\text{e}14, 6.10\text{e}14, 1.21\text{e}15, 2.74\text{e}16$ n/cm²)

Measurement of leakage current & capacitance as function of reverse detector bias V and dependent on T , f , Φ , material

Deep defects proportional to non ionizing energy loss (NIEL) generated by radiation:

$$I_{leak} = \alpha \Phi_{eq} V$$

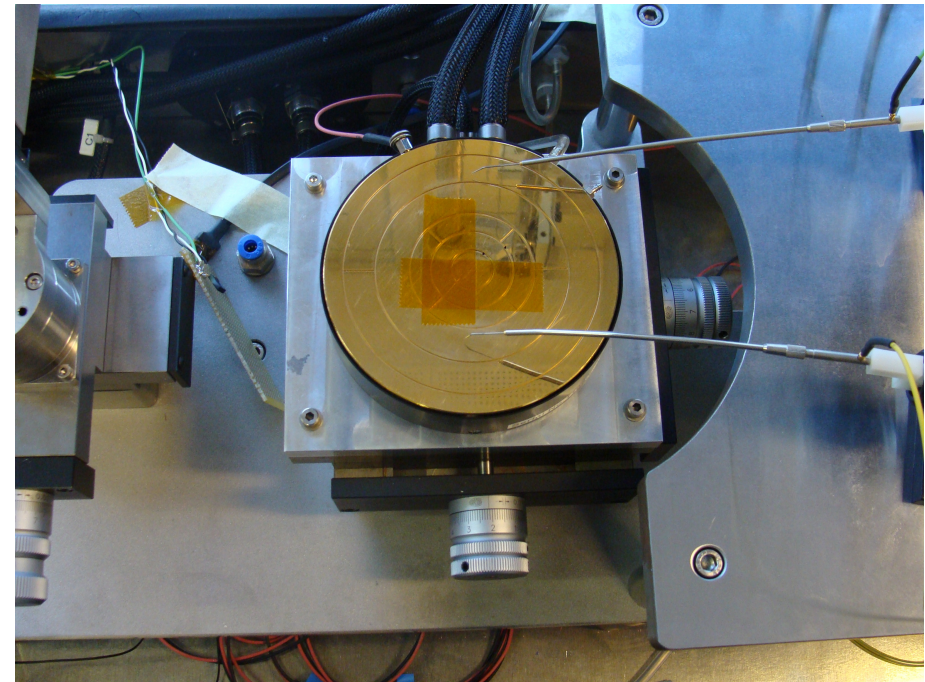
N_{eff} is related to depletion voltage and thickness of detector

→ information about N_{eff} :

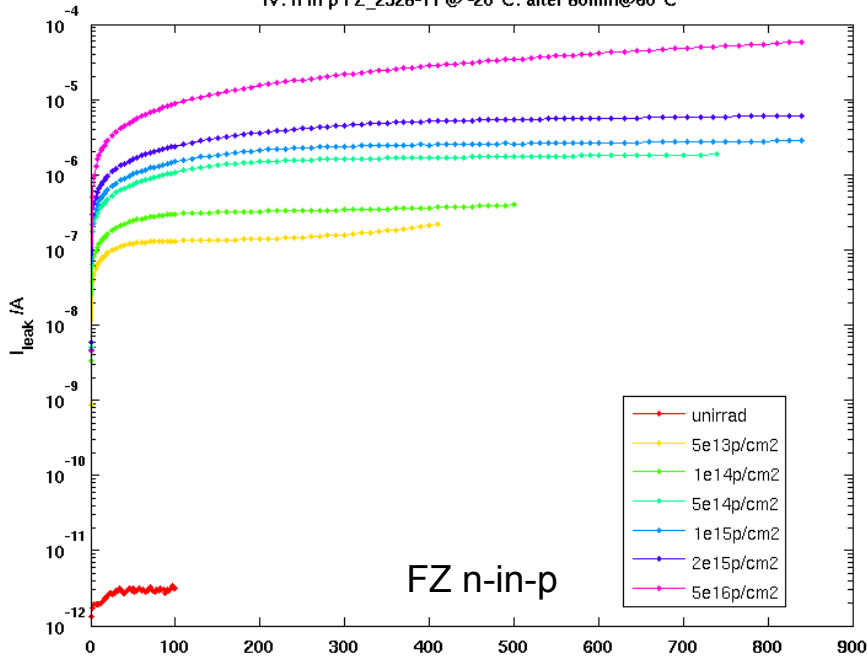
$$|N_{eff}| = \frac{2 \epsilon \epsilon_0 V_{fd}}{q_o d^2}$$

Parameters:

- GR to ground
- $T = 20, 10, 0, -10, -20^\circ\text{C}$
- Dry air
- $f = 1 \text{ kHz}, 455 \text{ Hz}$
- 80min@60°C annealing

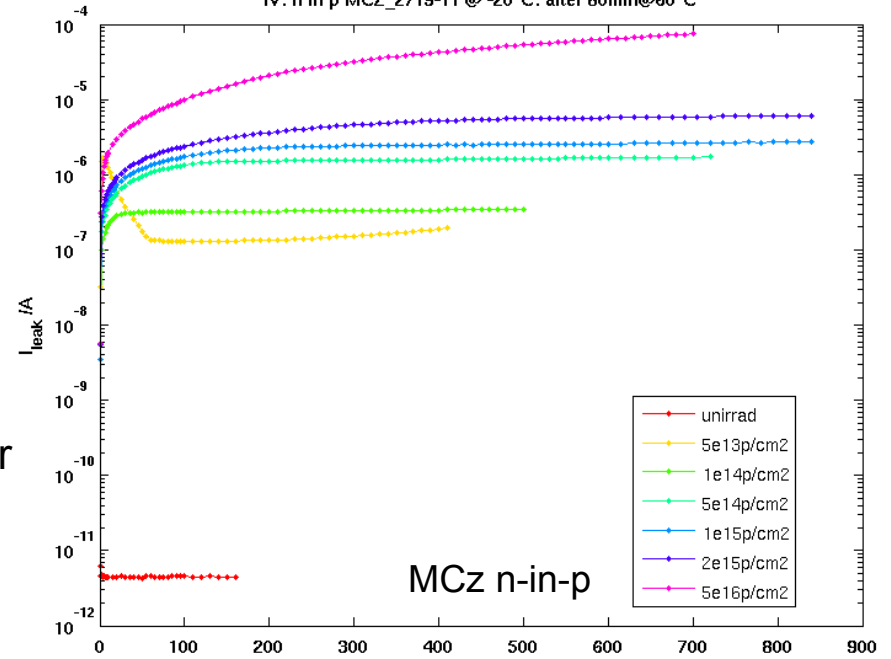


IV: n in p FZ_2328-11 @ -20°C: after 80min@60°C



FZ n-in-p

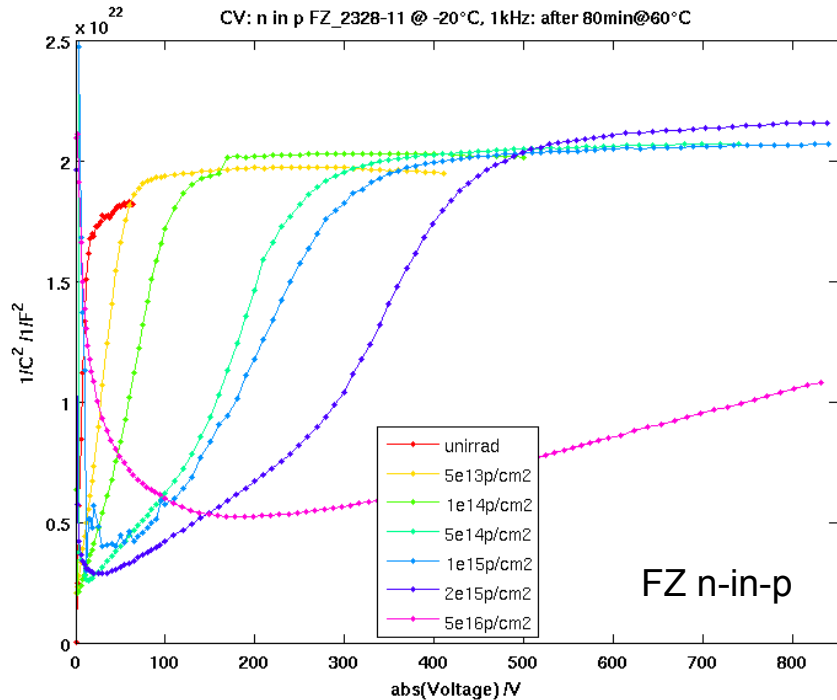
IV: n in p MCZ_2719-11 @ -20°C: after 80min@60°C



MCZ n-in-p

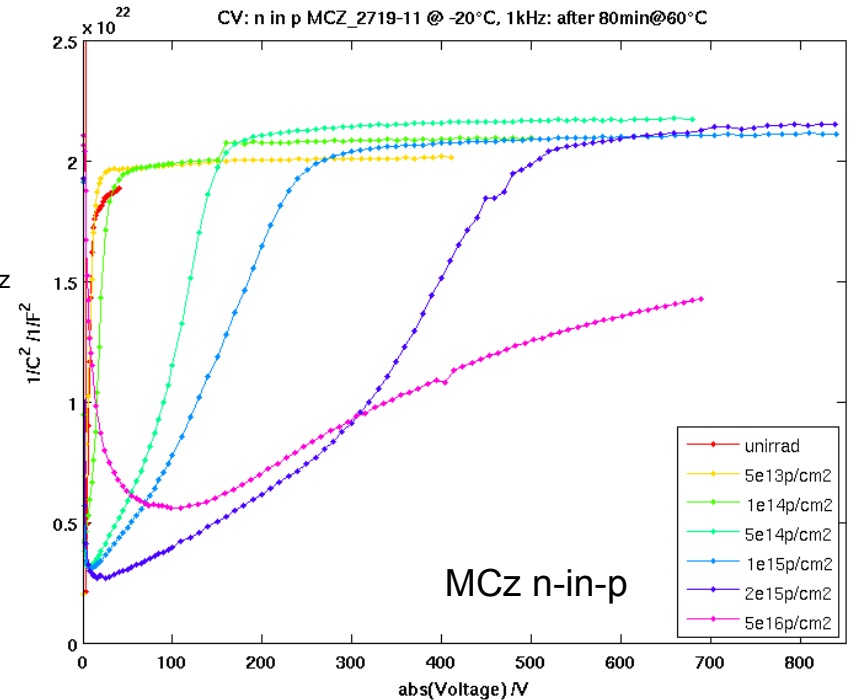
I_{leak} similar behaviour

CV: n in p FZ_2328-11 @ -20°C, 1kHz: after 80min@60°C



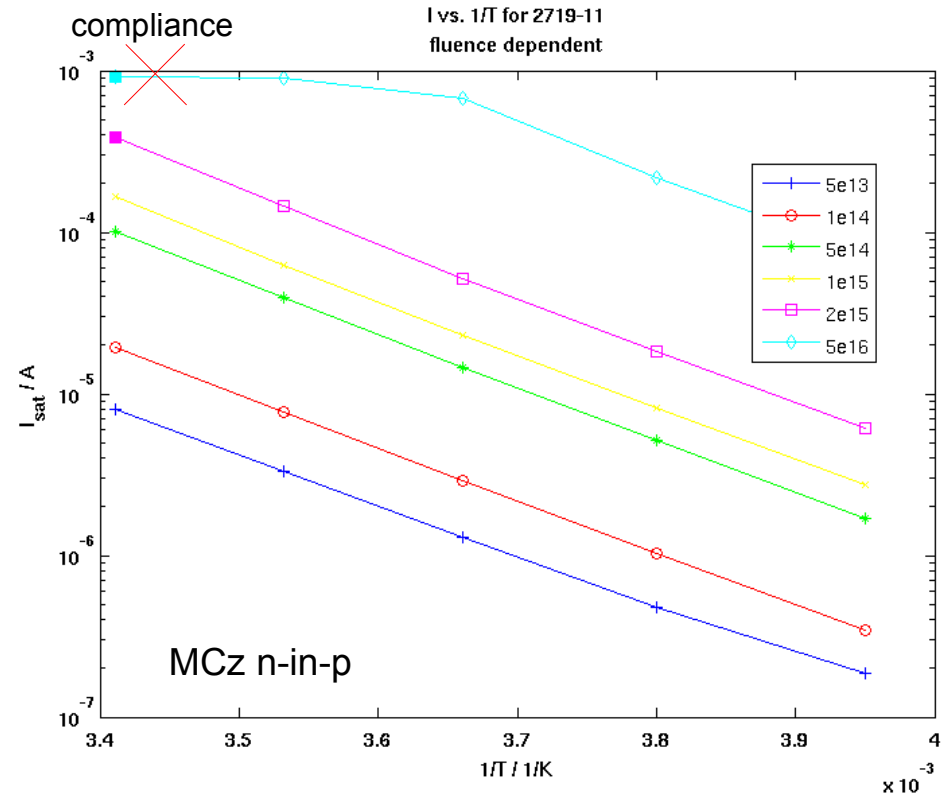
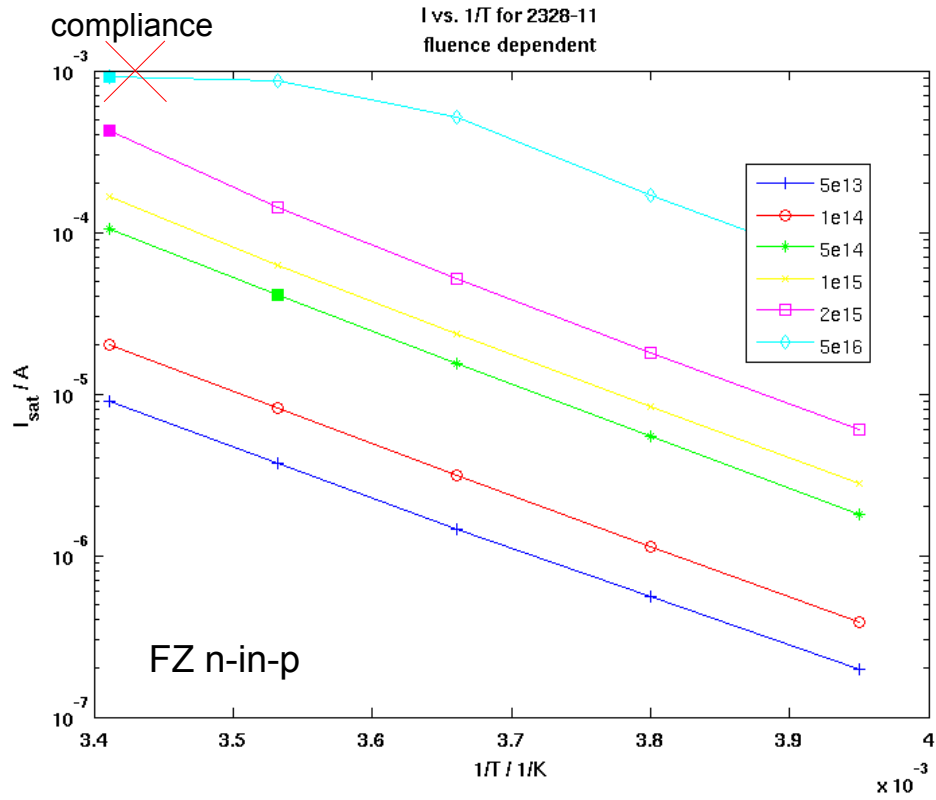
FZ n-in-p

CV: n in p MCZ_2719-11 @ -20°C, 1kHz: after 80min@60°C



MCZ n-in-p

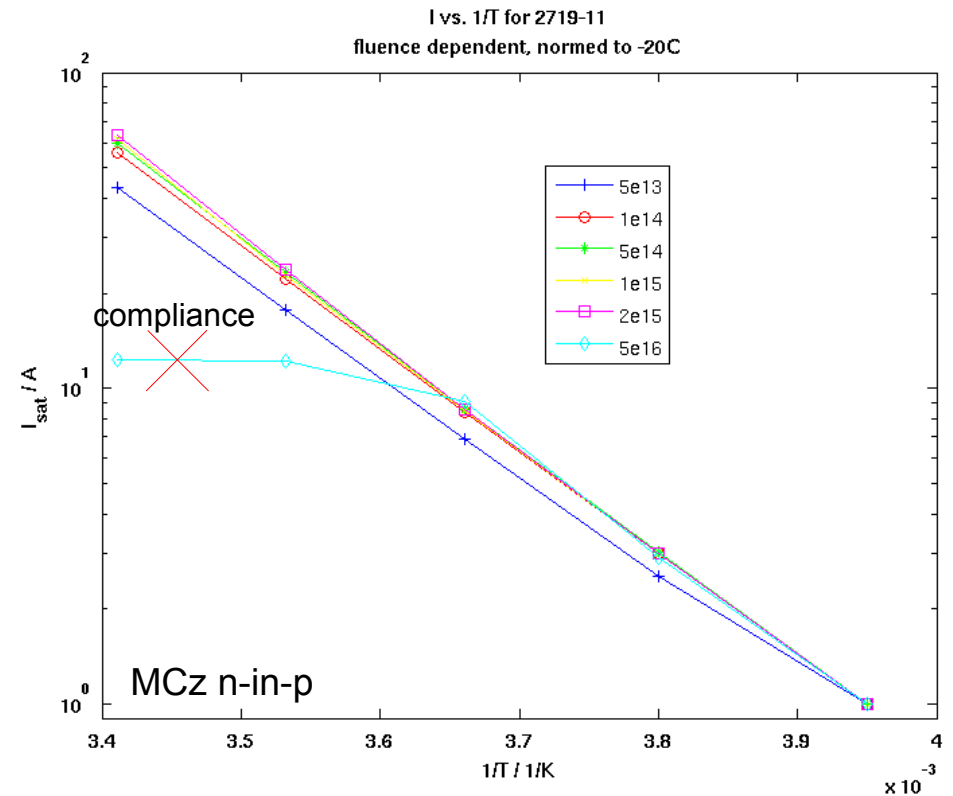
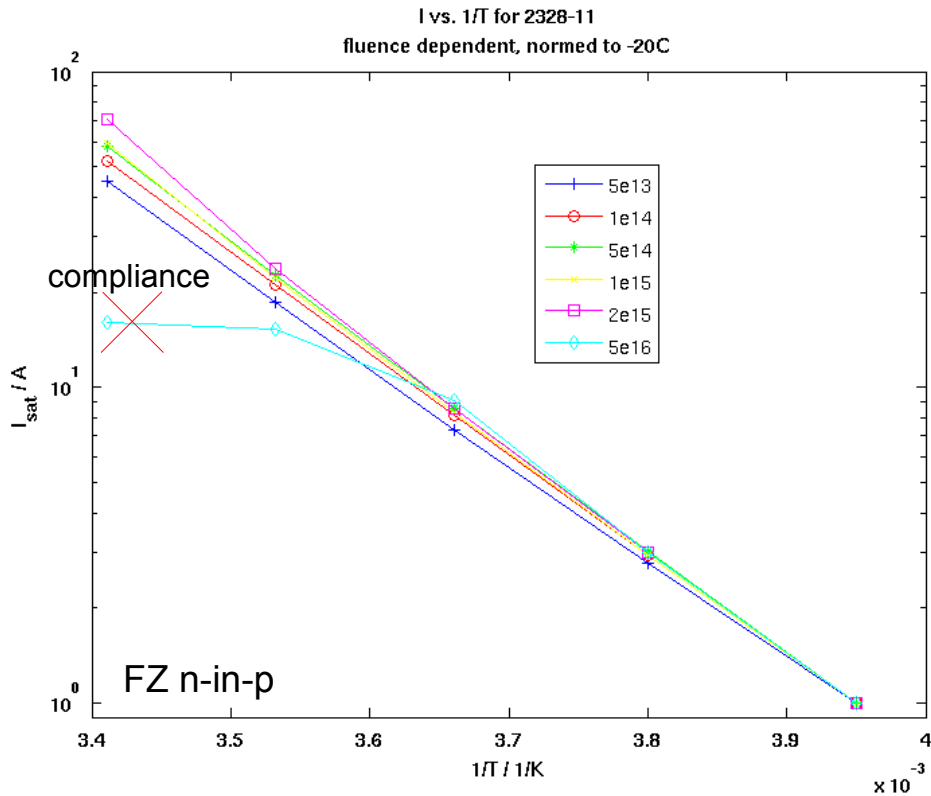
$V_{fd FZ} > V_{fd MCZ}$



$\ln I_{leak}$ scales linear with 1/T

$\rightarrow E_{eff} = 1.195 - 1.209 eV$

(compare A.Chilingarov $E_{eff} = 1.214 eV$)



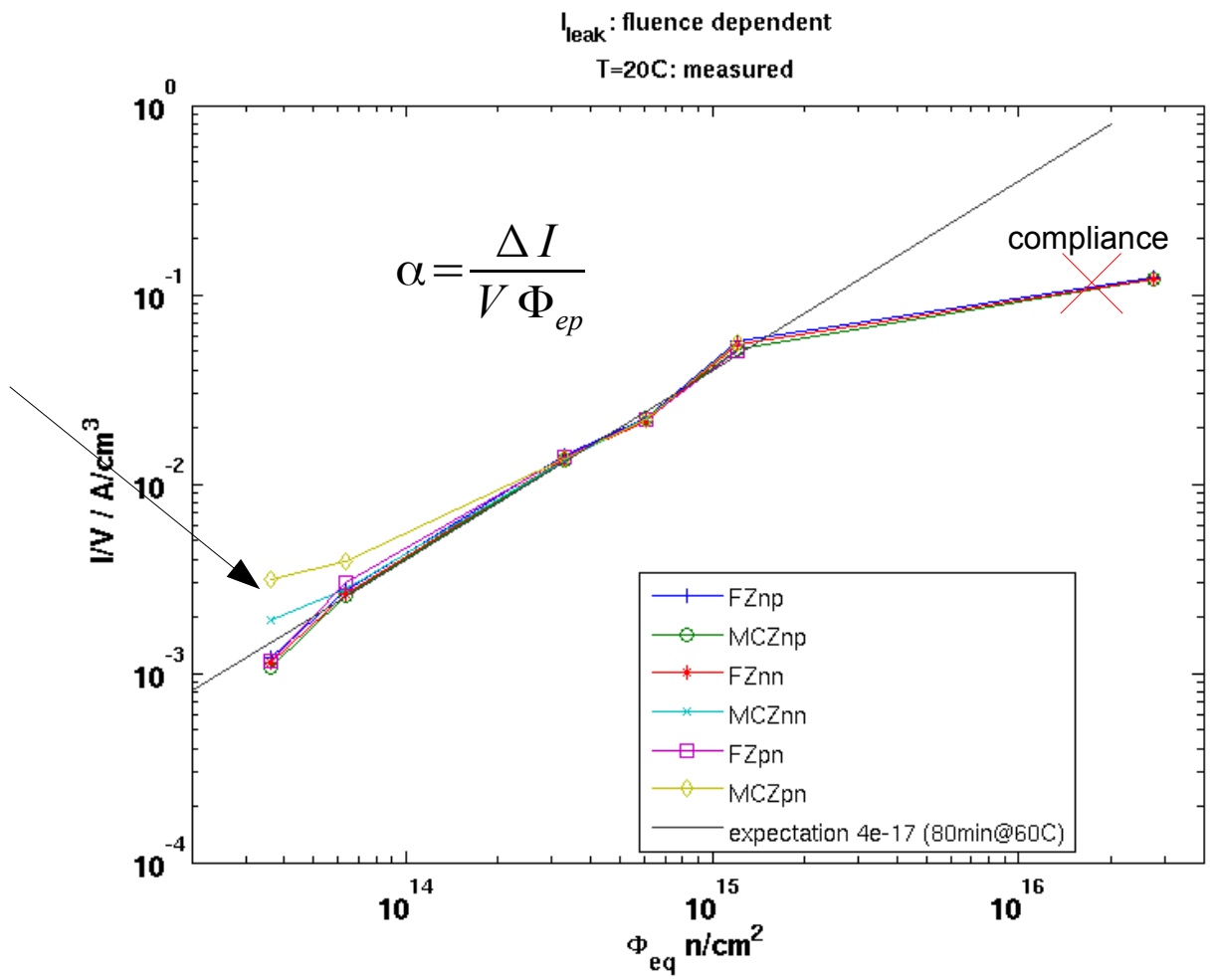
$\ln I_{leak}$ scales linear with $1/T$

$\rightarrow E_{eff} = 1.195 - 1.209\text{eV}$

(compare A.Chilingarov $E_{eff} = 1.214\text{eV}$)

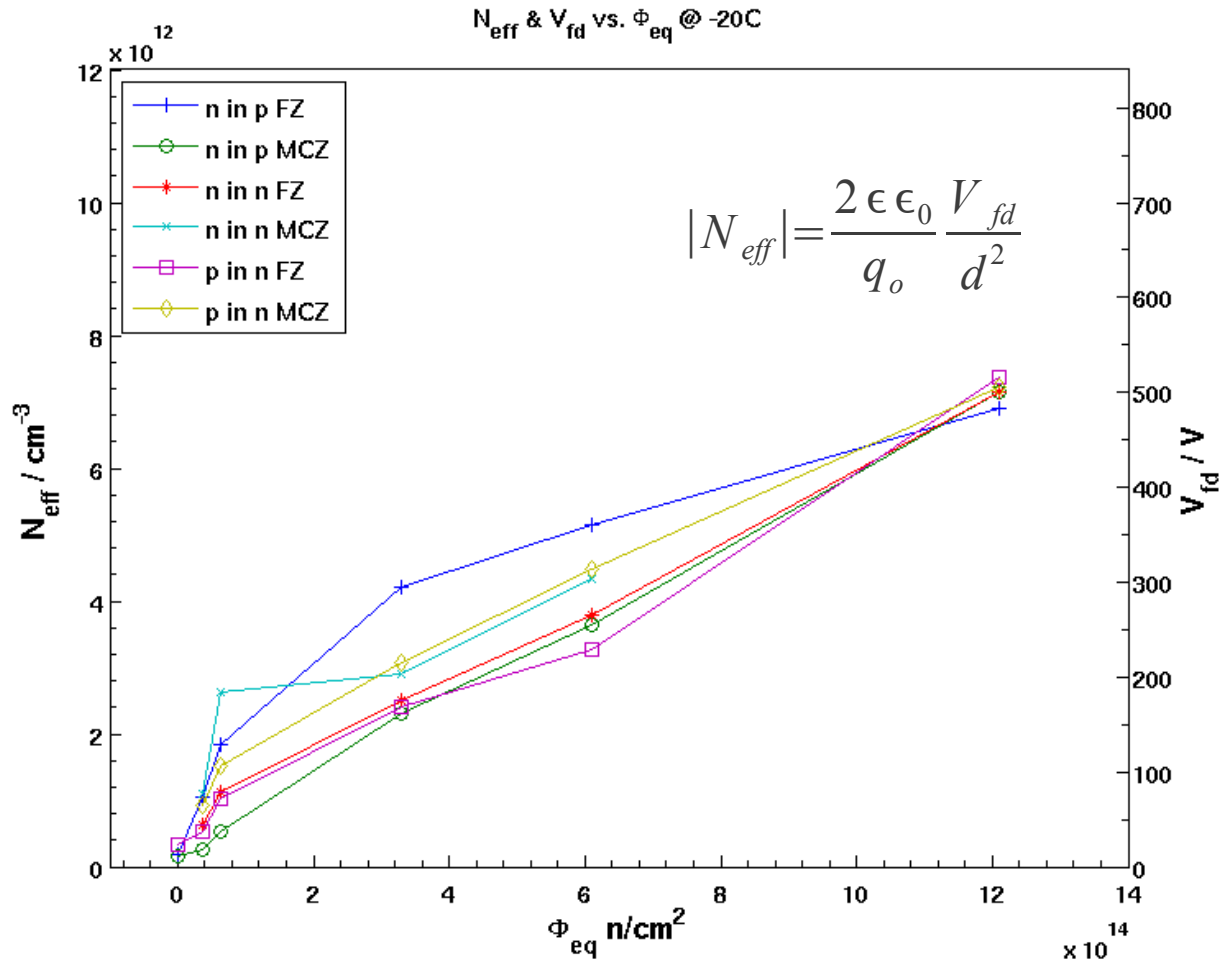
slopes differ according to the fluence: low Φ – "gentle" slope
high Φ – "steep" slope

- High leakage current of MCz (p-in-n and n-in-n) for non- and low irradiated samples
 - p-in-n MCz behaves like n-in-p
- stated by SR&SIMS measurement and seen in TCT



$\alpha = 4.38e-17 A/cm^2$

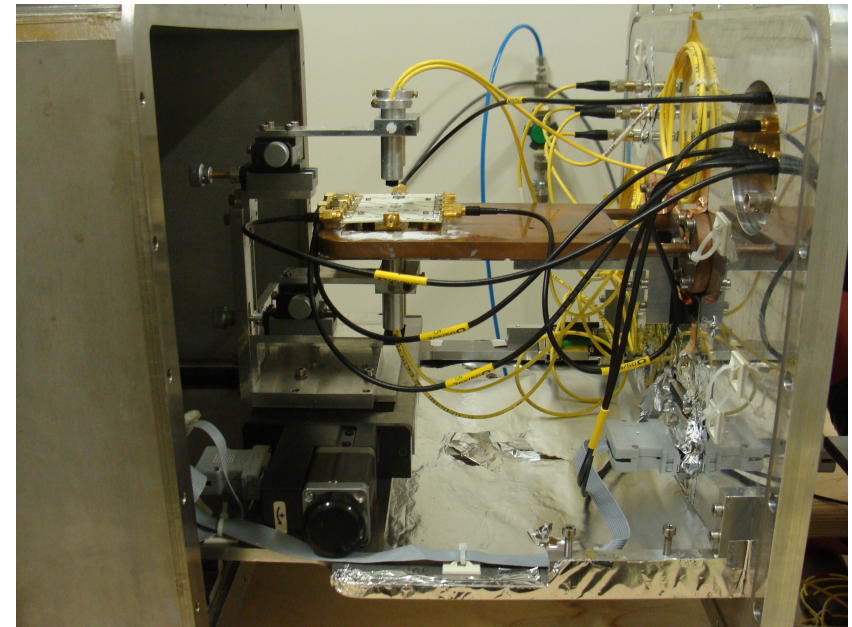
Damage parameter is nearly independent of leakage current per volume and material type. Almost linear increase between $1e13 cm^{-2}$ up to $2e15 cm^{-2}$.



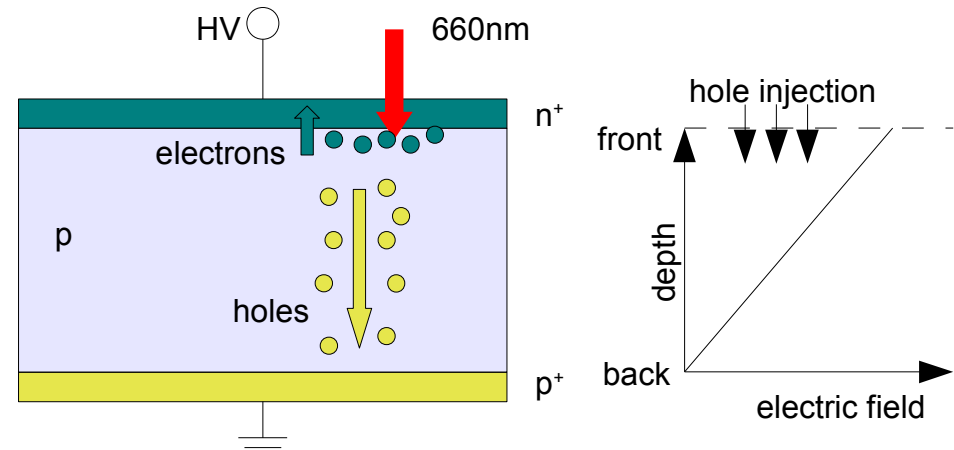
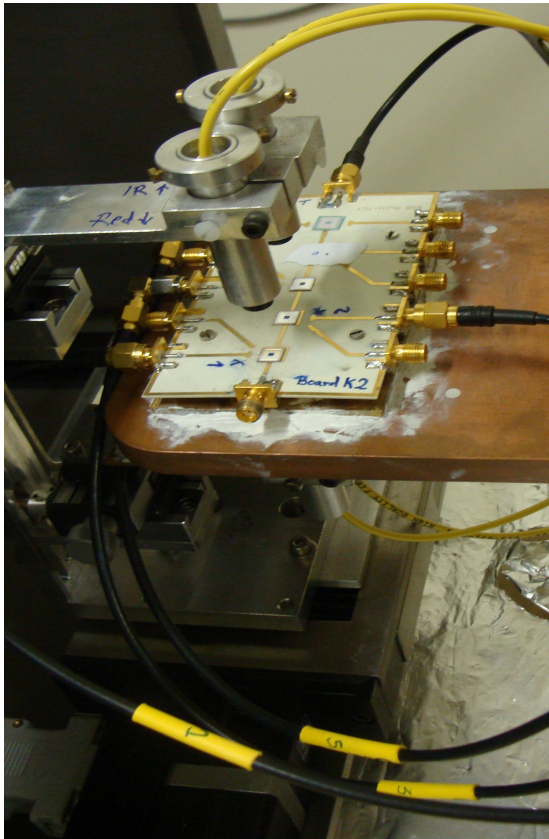
Comparison of effective doping concentration and depletion voltage for different materials dependent on the fluence (-20°C).

Next step: measure depletion voltage dependent on annealing, frequency and temperature

- Pulsed (ps) red/infrared laser illumination (front or back)
- Generates e-h-pairs in the detector
 - drift in externally applied electric field
 - record transient of induced current pulse



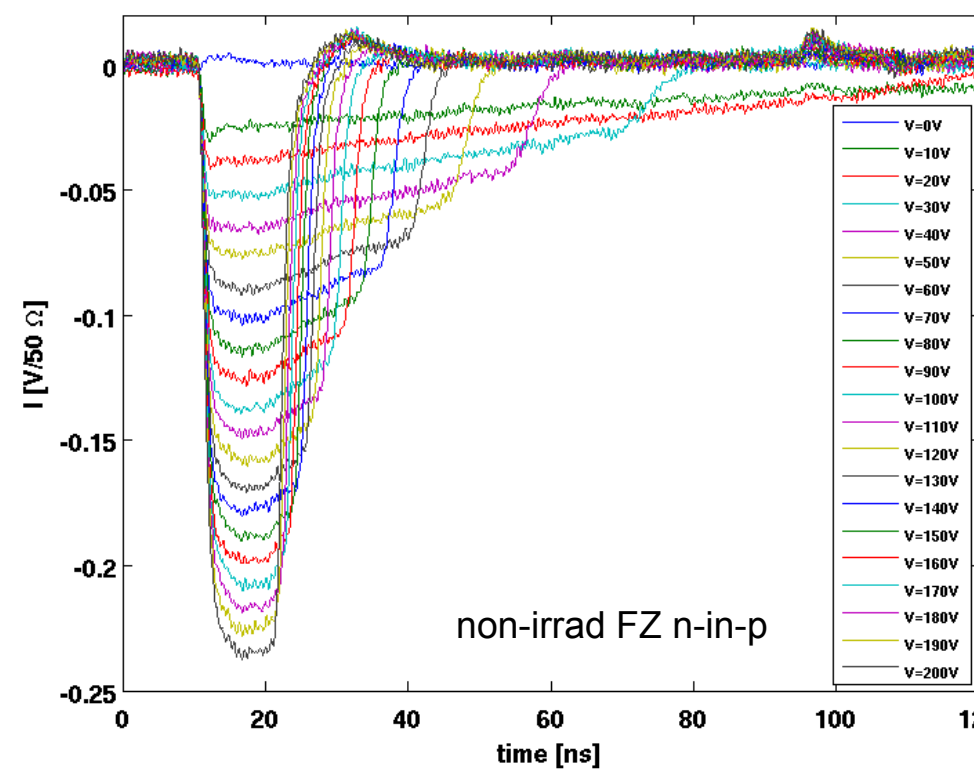
- Cooling to -20°C
- Red (665 nm) and Infrared (1060 nm) laser illumination
- FWHM pulse width 80 ps
- Miteq 1.5 GHz 44 dB low noise amplifier
- Agilent 2.5 GHz oscilloscope
- Detector bonded on thermally conductive PCB
- Front biasing, decoupling with 12 GHz BW Bias-Tee
- Laser delivery system with 4 focusers (front/back, red/IR)
- Humidity controlled: dry air atmosphere with dew point $< -50^{\circ}\text{C}$
- In-situ annealing of PCB with diodes possible



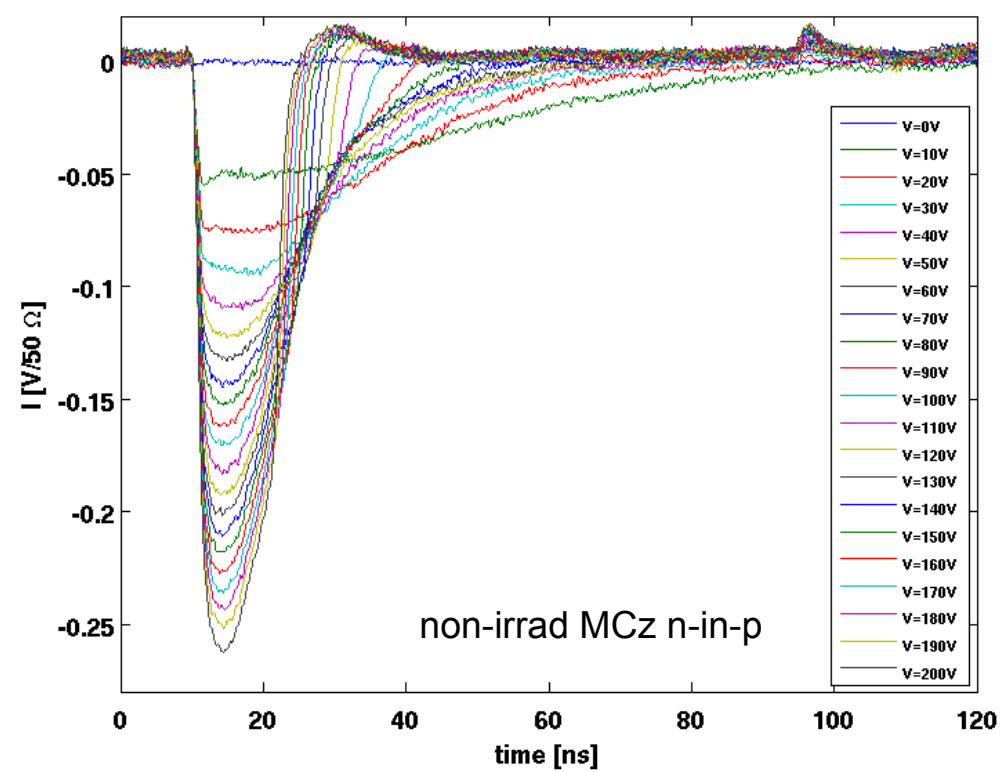
Induced current pulse from red TCT is generated by only one kind of charge carriers

→ possible to disentangle the separate contributions from electrons and holes

TCT Measurement @ T=22C (diodes with Al-etched backside)



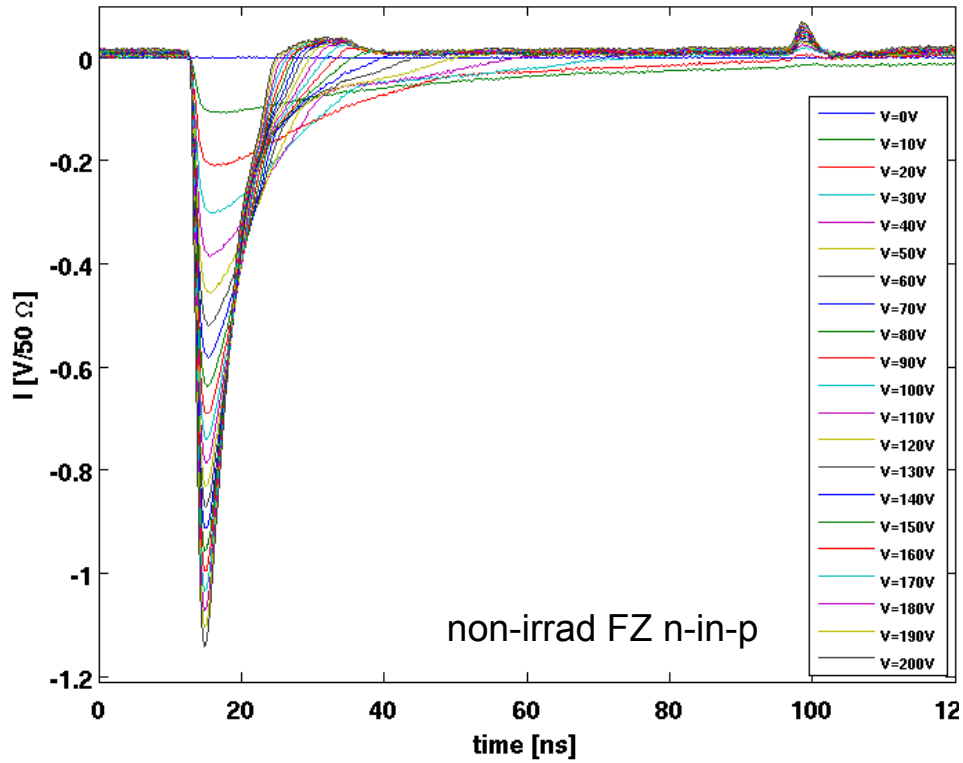
TCT Measurement @ T=22C (diodes with Al-etched backside)



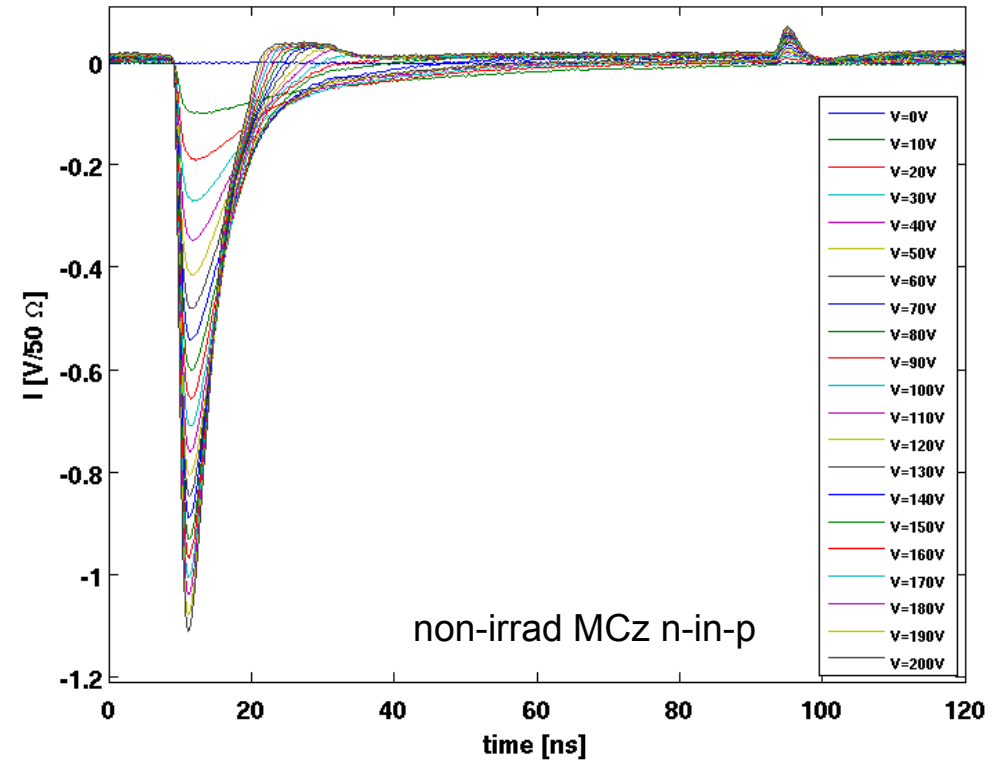
- Holes drift from a high to a low field for different voltages.

$$V_{\text{drift FZ}} < V_{\text{drift MCZ}}$$

TCT Measurement @ T=22C (diodes with Al-etched backside)

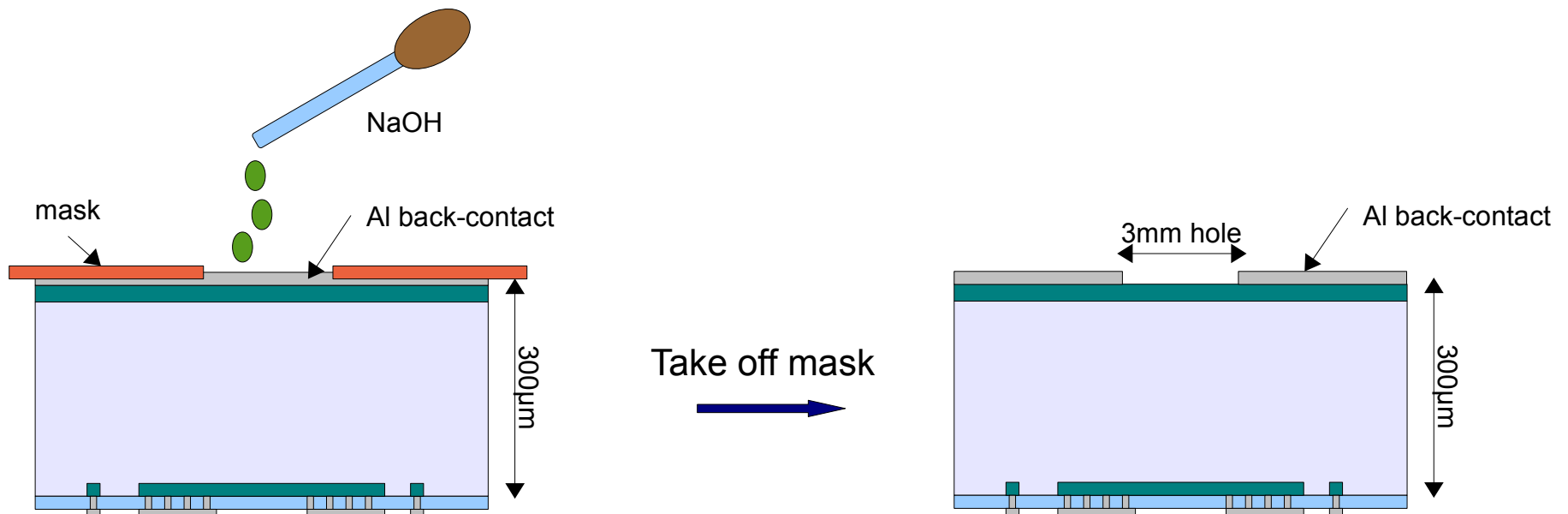


TCT Measurement @ T=22C (diodes with Al-etched backside)



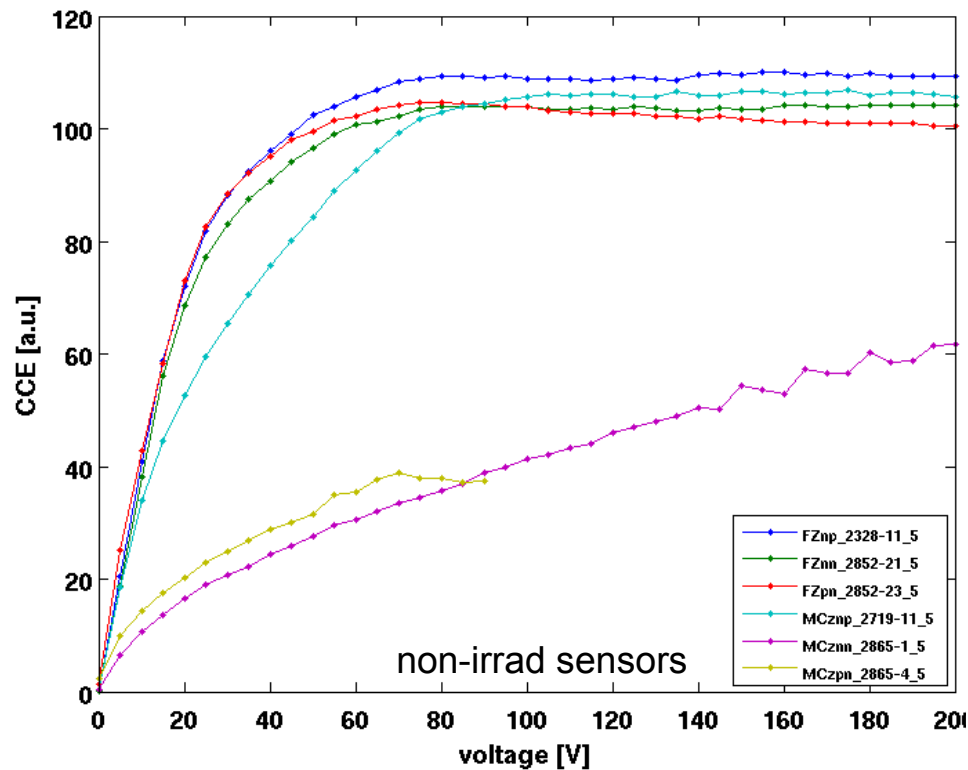
- TCT signals with IR illumination

- IR laser light for proper CCE measurement
→ homogeneous introduction of charge carriers and represent MIP
- Windows needed at both electrodes to avoid reflections
- Etching of full metallized Al-backside:
 - simple mask of kapton: holes of $d = 3\text{mm}$
 - sodium hydroxide solution (NaOH)

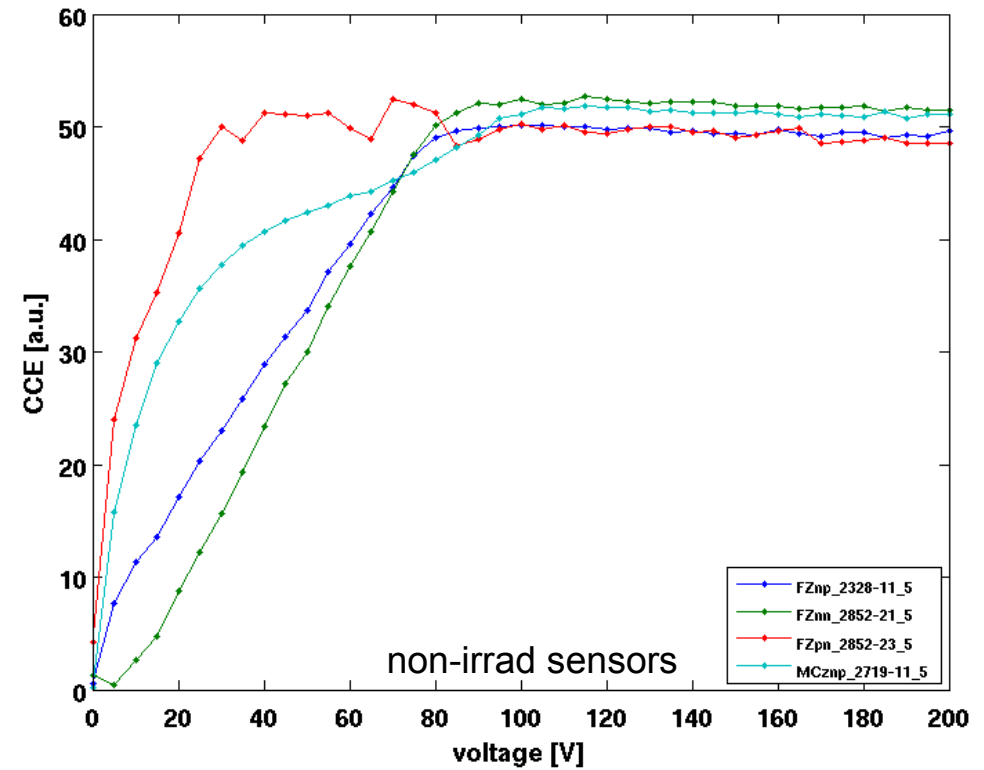


Comparison between IV/CV before and after Al-etching → no effect/changes!

TCT Measurement - CCE (25ns, IR)



TCT Measurement - CCE (25ns, Red & front)



- Charge collection efficiency (CCE) measured using TCT pulses
→ integration over the pulses: 25ns
- Non-irradiated sensors used as reference (100% CCE) compared to irradiated ones
- V_{fd} from CCE vs. CV:
→ frequency and temperature dependence of CV curve
→ extraction of effective working point of sensors from CCE (figure left: 25ns integr. time)

Conclusion:

- IV/CV study of irradiated Micron diodes:
 - Leakage current independent of material type, however:
MCz n-in-n and p-in-n show high current for low irradiation levels
 - I_{leak} scales linear with $1/T$: agreement with Chilingarov for E_{eff}
Slope dependent on fluence
 - fluence-dependence of N_{eff}
- TCT measurements with non-irradiated samples
 - Al-etching necessary for IR laser
 - drift velocity in MCz seems faster
- CCE properties through TCT-signal (both red and infrared) were measured on non-irradiated sample as reference for irradiated sensors

Outlook:

- TCT measurements with irradiated samples running
- Alibava and e-TCT measurements on strip sensors
(e-TCT runs with unirradiated strip detectors → Marcos: next talk)
- Annealing studies with diodes/strip sensor
- Comparison with simulation



Thank you for listening! Questions?!



Backups